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Physica C 280 (1997) 311–316

PHYSICA C

Magnetic force signal of vortex creation in type-II superconducting thin films

J.C. Wei ^a, L. Horng ^{b,*}, T.J. Yang ^a

^a Department of Electro-Physics, National Chiao-Tung University, Hsinchu, Taiwan, ROC

^b Department of Physics, National Changhua University of Education, Changhua, Changhua, 50058, Taiwan, ROC

Received 27 August 1996; revised 24 March 1997; accepted 27 March 1997

Abstract

The possibility of the formation of a vortex in thin film due to the field of magnetic dipole moment when a point dipole is vertically approaching the surface of a thin film is discussed. Calculations are performed for certain discrete values of the critical position of the point dipole for creating the vortex in the thin film and the equilibrium positions of the vortex, both of which depend on the strength of magnetic dipole moment. The creation of a new single vortex in the thin film causes an abrupt change in the vertical force. © 1997 Elsevier Science B.V.

1. Introduction

Magnetic force microscopy (MFM) has been applied to high- T_c superconductors, especially to investigate the flux line structures [1,2]. In particular, low-temperature is a powerful technique for accessing information on the stray field near the surface of superconductors. The mathematical modeling of the interaction of a stray magnetic field with a test magnet is a key to describing the magnetic force of MFM system. In this fascinating research area, the theories related to the interaction of magnetic fields with a magnetic probe tip for various geometry of superconductors have been established [3–8]. In a recent paper [7] we introduced a general theoretical approach to calculating the magnetic forces acting on

a point dipole above an infinite superconducting thin film in the mixed state based on the London theory.

In this work we consider the possibility of the formation of vortices in a thin superconducting film only in the field of magnetic dipole moment, i.e., the creation is due to the effect of vortices which are induced by the magnetic field of the dipole on the scanning process. We investigate the critical positions of the point dipole for creating the vortex in the thin film and the equilibrium distances between vortices for a various number (including the first, second and third vortices) of vortices to be created in sequence in the thin film. We also calculate the change of magnetic force acting on the point dipole after the vortex creation.

Assuming that the superconducting film lies in the xy plane with infinite area, and the point dipole tip is a given distance from the film boundary. The magnetic field of the dipole on the boundary of the film

* Corresponding author. Tel.: +886 (4) 7232105 ext. 3324; fax: +886 (4) 721-1153; e-mail: plhorng@ncue4680.ncue.edu.tw.

would be very small and negligible. The magnetic field near the upper pole and the lower pole have a stronger field, so we consider the appearance of a flux penetration in the film just below the dipole tip. From the energy point of view, a vortex can form in the film as the strength of field on the film surface increases, if the creation of a vortex is energetically favorable. This vortex penetrates perpendicular to the film surface, unlike the vortex penetration parallel to the surface of the semi-infinite sample for the Bean–Livingston case. One should note that the interaction of a vortex with its mirror image, just as has been done for Bean–Livingston surface barrier, should be removed. We can calculate the change of system energy after a vortex creation in the film.

Let us consider a magnetic point dipole with a moment m placed above an infinite superconducting film with a single vortex embedded in it. The energy of a vortex in the superconducting thin film is

$$U_v = \frac{\phi_0^2}{2\pi\mu_0\Lambda} \ln\left(\frac{\Lambda}{\xi}\right). \quad (1)$$

Where ϕ_0 is the flux quantum $h/2e$, μ_0 is the vacuum permeability, Λ is the effective penetration depth, and ξ is the coherence length. In the case of the single vortex in the superconducting film the interaction energy of the MFM system has been obtained [7,8] and the resulting interaction energy is

$$\begin{aligned} U_{\text{int}}(a) &= U_{\text{p-p}}(a) + U_{\text{p-v}}(a, r_0) \\ &= \frac{\mu_0 m^2}{8\pi} \int_0^\infty dk \frac{k^2}{k\Lambda + 1} e^{-ka} \\ &\quad - \frac{m\phi_0}{2\pi} \int_0^\infty dk \frac{k}{k\Lambda + 1} J_0(kr_0) e^{-ka}, \quad (2) \end{aligned}$$

where a is the separation between the dipole and the thin film, and r_0 is the lateral distance between the dipole and the vortex in the plane of thin film, which have the polar coordinates (r, θ) . The first term and the second term on the right-hand side of Eq. (2) represent the self-interaction energy [3,5–8] ($U_{\text{p-p}}$) caused by the screening currents (Meissner effect) and the interaction energy ($U_{\text{p-v}}$) between the dipole

and the vortex, respectively. Then the magnetic forces acting on the point dipole are

$$\begin{aligned} F_z &= \frac{\mu_0 m^2}{4\pi} \int_0^\infty dk \frac{k^3}{K\Lambda + 1} e^{-2ka} \\ &\quad - \frac{m\phi_0}{2\pi} \int_0^\infty dk \frac{k^2}{K\Lambda + 1} J_0(kr_0) e^{-ka} \\ &= F_1(a) + F_2(a, r_0), \quad (3) \end{aligned}$$

$$F_{r_0} = - \frac{m\phi_0}{2\pi} \int_0^\infty dk \frac{k^2}{k\Lambda + 1} J_1(kr_0) e^{-ka}, \quad (4)$$

where F_z is the vertical force and F_{r_0} is the lateral force. F_1 and F_2 are the forces acting on the point dipole in vertical (z) direction respectively caused by the screening currents and the vortex. The interaction force between the dipole and the vortex is attractive, and the interaction force between the dipole and the screening currents is repulsive.

2. Conditions of vortex creation

To simplify the analysis of vortex creation into the superconducting thin film, we assume a vortex is formed perpendicularly through the thin film one at a time when the dipole is vertically approaching the film surface along the $r = 0$ axis in $-z$ direction.

We consider the direction of the dipole moment normal to the plane of a type-II thin film of thickness d ($d \ll \lambda$, λ is the London penetration depth), and the dipole tip to be placed at a distance a above the surface of film. Below, we discuss the conditions of the creation of the first, second and third vortex in the thin film, respectively.

2.1. Creation of the first vortex

When a point dipole tip is lowered toward the surface of a superconducting film, persistent currents in the film are established which produce a magnetic field opposing that of the point dipole. The free energy of the system in the Meissner state is the self-interaction energy in Eq. (2) plus the self-energy of the point dipole. For expressing the free energy, we skipped the self-energy of the point dipole in the following calculation, because it is a constant term which diverges as the radius of the point dipole approaches to zero.

Further lowering the height of the dipole may create a vortex in the film because of an increase in magnetic field. Now we shall consider the creation of the first vortex in the thin film, if the point dipole is lowered to a position a_1 . In order to find the critical position a_1 , we need to compare the free energy of in the absence of a vortex and the free energy of the appearance of the first vortex compared to none in thin film. The free energy of the system before, U_0 , and after, U_1 , the creation of the first vortex are obtained, respectively, as follows.

$$U_0(a_1) = U_{p-p}(a_1) = \frac{\mu_0 m^2}{8\pi} \int_0^\infty dk \frac{k^2}{k\Lambda + 1} e^{-2ka_1}, \quad (5)$$

$$U(a_1) = U_{p-p}(a_1) + U_{p-v}(a_1, 0) + U_v = \frac{\mu_0 m^2}{8\pi} \int_0^\infty dk \frac{k^2}{K\Lambda + 1} e^{-ka_1} - \frac{m\phi_0}{2\pi} \int_0^\infty dk \frac{k}{K\Lambda + 1} e^{-ka_1} + U_v. \quad (6)$$

Here we assume the first vortex is created just below the point dipole.

The critical position of the point dipole a_1 for creating the first vortex in thin film can be found by setting $U_0 = U_1$. Then a_1 can be determined by the following equation,

$$\left[\frac{\Lambda}{a_1} - e^{a_1/\Lambda} E_1\left(\frac{a_1}{\Lambda}\right) \right] \alpha = \ln\left(\frac{\Lambda}{\xi}\right), \quad (7)$$

where $\alpha = \mu_0 m / \phi_0 \Lambda$ reflects the normalized strength of the magnetic moment, and $E_1(a_1/\Lambda)$ is an exponential integral. In Fig. 1, the critical position a_1 of the creation of the first vortex is plotted as a function of α for $\Lambda/\xi = 10^3$. To get analytic expression of a_1 , two extreme situations are considered, from Eq. (7) we obtain

$$a_1 = \sqrt{\frac{\alpha}{\ln\left(\frac{\Lambda}{\xi}\right)}}, \quad \text{for } \alpha \gg 1, \quad (8)$$

$$a_1 = \sqrt{\frac{\alpha\Lambda}{\ln\left(\frac{\Lambda}{\xi}\right)}}, \quad \text{for } \alpha \ll 1. \quad (9)$$

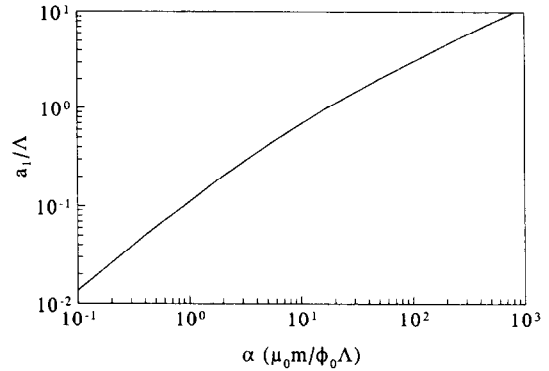


Fig. 1. The critical position a_1 , which is the position of the first vortex creation in the thin film, as a function of α for the parameter $\Lambda/\xi = 10^3$.

It is clear that a_1 depends on the strength of the magnetic moment. Both Eqs. (8) and (9) are reasonable by considering the problem in the appropriate cases. For $\alpha \gg 1$ case, for instance, the stronger the field a magnetic dipole moment has, the higher the position of the creation of the first vortex in the film is expected.

Let us find the change in magnetic force acting on the point dipole when the first vortex is created in the film. The forces acting on the dipole before, F_z , and after, F_{z1} , the creation of the first vortex can be obtained, respectively, as follows

$$F_z = F_1(a_1), \quad (10)$$

$$F_{z1} = F_1(a_1) + F_2(a_1, 0), \quad (11)$$

where F_z and F_{z1} represent the vertical force on the point dipole with none and one quanta of the flux in thin film, respectively. Eq. (11) shows clearly how the vertical force changed as the first vortex appears in the film. The force F_1 caused by the screening currents is still the same after the vortex creation. An additional force F_2 , caused by the vortex, is found after the vortex creation. The difference in the vertical force between the first vortex appears and no vortex exists in the film, $|\Delta F_z|$, is

$$|\Delta F_z| = |F_2(a_1)| = \frac{m\phi_0}{2\pi\Lambda^3} \left[-\left(\frac{\Lambda}{a_1}\right) + \left(\frac{\Lambda}{a_1}\right)^2 + e^{a_1/\Lambda} E_1\left(\frac{a_1}{\Lambda}\right) \right]. \quad (12)$$

Taking two limitations in Eq. (12), we have

$$|\Delta F_z| = \frac{m\phi_0}{\pi a_1^3} \left(1 - 3\frac{\Lambda}{a_1}\right), \quad \text{for } a_1 \gg \Lambda, \quad (13)$$

$$|\Delta F_z| = \frac{m\phi_0}{2\pi a_1^2 \Lambda}, \quad \text{for } a_1 \ll \Lambda. \quad (14)$$

2.2. Creation of the second vortex

When the point dipole continues to approach the surface of thin film, increasing in magnetic field, the possibility of creation of the second vortex appears. To perform the corresponding calculations we should know the interaction energy of two vortices. The interaction energy between two vortices in the case of infinitely thin superconducting film was obtained [9,10] and is of the form

$$U_{12}(r) = \frac{\phi_0^2}{2\mu_0 \Lambda} \left[H_0\left(\frac{r}{\Lambda}\right) - Y_0\left(\frac{r}{\Lambda}\right) \right], \quad (15)$$

where r is the distance between two vortices, H_0 is the Struve function of order zero and Y_0 is the Bessel function of the second kind of order zero. If the point dipole is lowered down to a position a_2 , the creation of the second vortex in thin film appears. The free energy before, U_1 , and after, U_2 , the creation of the second vortex, respectively, may be written as

$$U_1(a_2) = U_{p-p}(a_2) + U_{p-v}(a_2, 0) + U_v, \quad (16)$$

$$U_2(a_2) = U_{p-p}(a_2) + 2U_{p-v}(a_2, r_1) + 2U_v + U_{12}(r), \quad (17)$$

where $r = 2r_1$ is the distance between two vortices and r_1 is the equilibrium position of the vortex from the origin (or equilibrium center). We assume that there exists a position of stable equilibrium for the vortex, the attractive force between the dipole and the vortex and the repulsive force between two vortices balanced each other. We do not consider these two vortices coinciding because they need more energy to form a two-quanta vortex. In the following we express the procedures to find a_2 and r_1 .

The critical condition that the system free energy before and after the creation of the second vortex is equal for the system $U_1(a_2) = U_2(a_2)$; we have $2U_{p-v}(a_2, r_1) - U_{p-v}(a_2, 0) + U_v + U_{12}(r) = 0$.

$$(18)$$

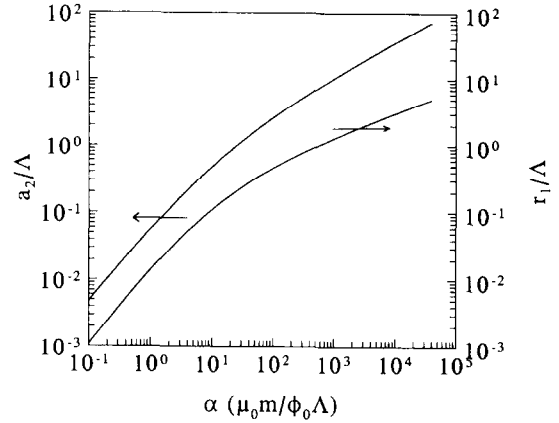


Fig. 2. The critical position a_2 of the creation of the second vortex and the equilibrium positions r_1 of the vortices as a function of α for the parameter $\Lambda/\xi = 10^3$.

The condition for equilibrium of vortices is

$$F_r = -\frac{\partial U_2(a_2)}{\partial r_1} = 0. \quad (19)$$

Applying these two conditions of Eqs. (18) and (19) to determine a_2 and r_1 ; we have

$$\alpha \int_0^\infty dt \frac{te^{-(a_2/\Lambda)t}}{t+1} \left[2J_0\left(\frac{r_1}{\Lambda}t\right) - 1 \right] = \ln\left(\frac{\Lambda}{\xi}\right) + \pi \left[H_0\left(\frac{2r_1}{\Lambda}\right) - Y_0\left(\frac{2r_1}{\Lambda}\right) \right], \quad (20)$$

$$\alpha \int_0^\infty dt \frac{te^{-(a_2/\Lambda)t}}{t+1} J_1\left(\frac{r_1}{\Lambda}t\right) = \pi \left[H_1\left(\frac{2r_1}{\Lambda}\right) - Y_1\left(\frac{2r_1}{\Lambda}\right) - \frac{2}{\pi} \right]. \quad (21)$$

Fig. 2 shows the critical position a_2 and the equilibrium position r_1 versus α (the normalized strength of the magnetic moment). The height of the critical position a_2 is lower than that of the critical position a_1 for the same reduced magnet moment. The change in vertical force acting on the point dipole due to the second vortex formation in the thin film can be written as

$$|\Delta F_z| = \frac{m\phi_0}{2\pi} \int_0^\infty dk \frac{k^2 e^{-ka_2}}{k\Lambda + 1} [2J_0(kr_1) - 1]. \quad (22)$$

This integral is finite and convergent. In the case $r_1 \ll \Lambda$, we can limit ourselves to a second-order

calculation, i.e., the approximation $J_0(kr_1) \cong 1 - \{k^2 r_1^2\}/4$, then we obtain

$$|\Delta F_z| = \frac{m\phi_0}{2\pi\Lambda^3} \left[-\left(\frac{\Lambda}{a_2}\right) + \left(\frac{\Lambda}{a_2}\right)^2 + e^{a_2/\Lambda} E_1\left(\frac{a_2}{\Lambda}\right) \right] - \frac{m\phi_0}{4\pi\Lambda^3} \left(\frac{r_1}{\Lambda}\right)^2 \left[-\left(\frac{\Lambda}{a_2}\right) + \left(\frac{\Lambda}{a_2}\right)^2 - 2\left(\frac{\Lambda}{a_2}\right)^3 + 6\left(\frac{\Lambda}{a_2}\right)^4 + e^{a_2/\Lambda} E_1\left(\frac{a_2}{\Lambda}\right) \right]. \tag{23}$$

From the result of Fig. 2, we see that the values of a_2 are much smaller than the effective penetration depth Λ for $r_1 \ll \Lambda$. We use here the condition $a_2 \ll \Lambda$; from Eq. (23) we obtain

$$|\Delta F_z| = \frac{m\phi_0}{2\pi\Lambda^3} \left(\frac{\Lambda}{a_2}\right)^2 \left[1 - 3\left(\frac{r_1}{a_2}\right)^2 \right]. \tag{24}$$

For small r_1/Λ (< 0.1), the values of r_1/a_2 are about 0.21 to 0.26 for a range of α from 0.1 to 10.

2.3. Creation of the third vortex

In the following, let us treat the problem of three vortices. For simplicity, we assume that these vortices to form an equilateral triangle. Following similar procedure, we have

$$\alpha \int_0^\infty dt \frac{t e^{-(a_3/\Lambda)t}}{t+1} \left[3J_0\left(\frac{r_3}{\Lambda}t\right) - 2J_0\left(\frac{r_2}{\Lambda}t\right) - 1 \right] = \ln\left(\frac{\Lambda}{\xi}\right) - \pi \left[H_0\left(\frac{2r_2}{\Lambda}\right) - Y_0\left(\frac{2r_2}{\Lambda}\right) \right] + 3\pi \left[H_0\left(\frac{\sqrt{3}r_3}{\Lambda}\right) - Y_0\left(\frac{\sqrt{3}r_3}{\Lambda}\right) \right], \tag{25}$$

$$\alpha \int_0^\infty dt \frac{t^2 e^{-(a_3/\Lambda)t}}{t+1} J_1\left(\frac{r_2}{\Lambda}t\right) = \pi \left[H_1\left(\frac{2r_2}{\Lambda}\right) - Y_1\left(\frac{2r_2}{\Lambda}\right) - \frac{2}{\pi} \right], \tag{26}$$

$$\alpha \int_0^\infty dt \frac{t^2 e^{-(a_3/\Lambda)t}}{t+1} J_1\left(\frac{r_3}{\Lambda}t\right) = \sqrt{3} \pi \left[H_1\left(\frac{\sqrt{3}r_3}{\Lambda}\right) - Y_1\left(\frac{\sqrt{3}r_3}{\Lambda}\right) - \frac{2}{\pi} \right], \tag{27}$$

where a_3 is the critical position of the point dipole for creating the third vortex in the film and r_2 and r_3 specify the equilibrium positions of the vortex from the origin for the system before and after the creation of the third vortex, respectively. Fig. 3 shows the critical position a_3 and the equilibrium position r_2 and r_3 versus α (the normalized strength of the magnetic moment). The critical position a_3 becomes closer to the surface of the film than those of a_2 and a_1 . It also can be seen from Fig. 3 that the equilibrium position of the vortex (or the distance between vortices) becomes farther than the position it was after the creation of the third vortex. The change in vertical force acting on the dipole after the creation of the third vortex in the film is

$$|\Delta F_z| = \frac{m\phi_0}{2\pi} \int_0^\infty dk \frac{k^2 e^{-ka_1}}{k\Lambda + 1} \times [3J_0(kr_3) - 2J_0(kr_2)]. \tag{28}$$

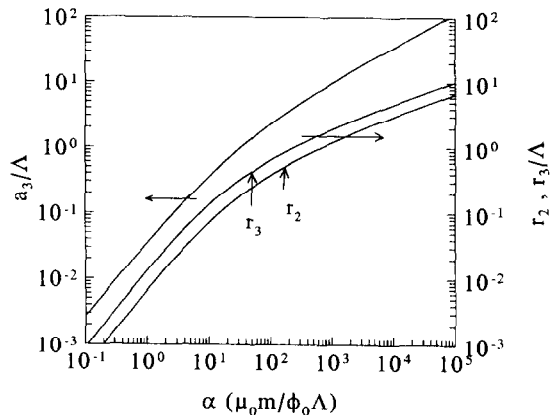


Fig. 3. The critical position a_3 of the creation of the third vortex and the equilibrium positions r_2 and r_3 as a function of α for the parameter $\Lambda/\xi = 10^3$, where r_2 and r_3 specify the equilibrium positions of the vortex before and after the formation of the third vortex, respectively.

Again in the $r_2, r_3 \ll \Lambda$ limit, we have

$$|\Delta F_z| = \frac{m\phi_0}{2\pi\Lambda^3} \left[-\left(\frac{\Lambda}{a_3}\right) + \left(\frac{\Lambda}{a_3}\right)^2 + e^{a_3/\Lambda} E_1\left(\frac{a_3}{\Lambda}\right) \right] - \frac{m\phi_0}{8\pi} \left(\frac{3r_3^2 - 2r_2^2}{\Lambda^5} \right) \left[-\left(\frac{\Lambda}{a_3}\right) + \left(\frac{\Lambda}{a_3}\right)^2 - 2\left(\frac{\Lambda}{a_3}\right)^3 + 6\left(\frac{\Lambda}{a_3}\right)^4 + e^{a_3/\Lambda} E_1\left(\frac{a_3}{\Lambda}\right) \right], \quad (29)$$

and

$$|\Delta F_z| = \frac{m\phi_0}{2\pi\Lambda^3} \left(\frac{\Lambda}{a_3}\right)^2 \left[1 - \frac{3}{2} \left(\frac{3r_3^2 - 2r_2^2}{a_3^2} \right) \right],$$

for $a_3 \ll \Lambda$. (30)

The values of r_2/a_3 and r_3/a_3 are about 0.17 to 0.20 and 0.34 to 0.39, respectively, for a range of α from 0.1 to 10.

3. Conclusions

We have demonstrated that presence of the field of a point dipole tip may lead to vortex formation in thin superconducting films. The condition of the vortex creation and the change in magnetic force on the point dipole for various numbers of vortices, including the first, second and third vortices cases, in the absence of free from pinning center in the thin film have been examined. There is a change in vertical force which acts on the point dipole when a new single vortex is created in the film. The force changes discontinuously as the vortex is created in the film. In the free of pinning centers case, there is

no lateral force signal owing to the symmetry of vortex geometry. The numerical results of the critical positions of the point dipole for creating the vortex and equilibrium positions of the vortex for various strengths of the magnetic moment can help us to realize the microscopic character of the MFM.

Acknowledgements

We thank Dr. J.L. Chen for helpful discussions and correspondence. This research was supported by the National Science Council of the Republic of China under Grant No. NSC 86-2112-M-009-007-PH and Grant No. NSC 85-2112-M-018-007.

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